

韩国食品级测试KFDA检测机构-第三方KFDA测试公司

产品名称	韩国食品级测试KFDA检测机构- 第三方KFDA测试公司
公司名称	东莞市通标科技服务有限公司
价格	.00/件
规格参数	
公司地址	东莞市长安镇乌沙社区振安东路249号恒邦智创 云谷11楼1125（注册地址）
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产品详情

韩国食品级测试KFDA（ ）

专业提供各类出往韩国市场的食品接触类材料的KFDA检测、KFDA测试一站式专业办理，

常见的KFDA测试材料和测试项目如下：

KFDA 韩国

Material

Test Item

合成树脂Synthetic Resin (general standard)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

(except for PF, UF, MF, POM)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

PVC聚氯乙炔

Dibutyltin

Vinylchloride Monomer(VCM)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

phthalates(DBP,BBP,DEHP,DnOP,DINP,DIDP,DEHA)

(in water, 4% acetic acid, 20% ethanol and n-heptane)

Cresylphosphoric ester

PP,EVA, PPS,PMP(polymethylpentene), PVA(Polyvinyl Alcohol),

PB-1(Polybutene-1), Polyimide(PI), Hydroxybutyl(HBP), Fluoro Resins(FR), Ionomer resin, Polyethylene naphthalate(PEN), Ethylene Vinyl Polyetheretherketone(PEEK),

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

PS 聚苯乙烯

Polyphenylene ether

(PPE),聚亚苯基氧化物树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate (Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Volatile matter

PVDC聚偏二氯乙烯包装材料

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Barium

Vinylidene chloride

PET涤纶树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Soluble Antimony in 4% acetic acid(Elution)

Soluble Germanium in 4% acetic acid(Elution)

Terephthalic acid (elution)

Isophthalic acid(Elution)

PF(Phenol formaldehyde)苯酚甲醛树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Phenol(Elution-4% acetic acid)

Formaldehyde(Elution-4% acetic acid)

MF (melamineformaldehyde) 三聚氰胺甲醛树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Phenol(Elution-4% acetic acid)

Formaldehyde(Elution-4% acetic acid)

melamine(Elution-4% acetic acid)

UF (ureaformaldehyde)尿醛树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Phenol(Elution-4% acetic acid)

Formaldehyde(Elution-4% acetic acid)

Acrylic resin丙烯酸树脂亚克力树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Methylmethacrylate(Elution-20% ethanol) (contains over 50% methylmethacrylate)

PA尼龙

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

4,4'-methylenedianiline(Elution-4% acetic acid)

Ethylenediamine(Elution)

Hexamethylenediamine(Elution)

Caprolactam(Elution-20% ethanol)

PC 聚碳酸酯

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

BPA(include phenol, BPA,pt-butylphenol)

Bisphenol A(Elution-include phenol, BPA,pt-butylphenol))

Diphenylcarbonate

Amines(Triethylamine and tributylamine)

PU 聚胺酯树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

4,4'-methylenedianiline(acetic acid)

isocyanate(in water, 4% acetic acid, 20% ethanol and n-heptane)

ABS, AS丙烯腈共聚物 苯乙烯共聚物

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Volatile matter

1,3-butadiene

Acrylonitrile(Elution-water)(

(MS)Polymethacrylstyrene聚苯乙烯

Volatile matter

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Methylmethacrylate(Elution-20% ethanol)

PAN平底锅，盘子

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Acrylonitrile(Elution-water)

MABS ABS添加/PMMA共合 成的透明级的ABS

Volatile matter

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

1,3-butadiene

Acrylonitrile(Elution-water)

Methylmethacrylate(Elution-20% ethanol)

4,4'-methylenedianiline(acetic acid)

Epoxy resin环氧树脂

BPA(Elution-include phenol, BPA,pt-butylphenol))

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

BPA diglycidyl ether(elution)

BPA F diglycidyl ether(elution)

Epichlorohydrin(elution-n-heptane)

Amines

聚酯PCT

Terephthalic acid (elution)

Isophthalic acid(Elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Antimony in 4% acetic acid

PE聚乙烯

1- hexane(elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

1-octene(elution)

Polyarylsulfone(PASF)聚芳砜

Bisphenol A(Elution-include phenol, BPA,pt-butylphenol)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

4,4'-dichlorodiphenyl sulfone(Elution)

PES聚醚砜树脂

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

4,4'-dichlorodiphenyl sulfone(Elution)

POM 聚甲醛

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Formaldehyde(Elution-4% acetic acid)

聚酯PBT

Terephthalic acid (elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Isophthalic acid(Elution)

PAR聚芳酯

Terephthalic acid (elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Isophthalic acid(Elution)

聚酯 PLA/PBSA

As(elution)

formaldehyde in 4% acetic acid (elution)

flurescent matter

PMPpolymethylpentene聚甲基戊烯

4-methyl-1-pentene (elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

PPS(poly(phenylenesufide)聚苯硫醚

1,4-dichlorobenzene(elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Crosses-linked polyester resin聚脂树脂

Terephthalic acid (elution)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

Heavy metal as lead(Elution)

Consumption of Potassium Permanganate(Elution)

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

Isophthalic acid(Elution)

玻璃纸 cellophane

(regenerated cellulose film)

As in 4% acetic acid (elution)

total Pb

total Cd

total Hg

total Cr(VI)

Heavy metal as lead (Elution)

Evaporation Residues (4% acetic acid)

Rubber,silicone resin,BDR(Butadiene resins), TPE橡胶 , 弹性体

2-mercaptoimidazoline

Total lead

Total cadmium

Heavy metal as lead in 4% acetic acid

Evaporation Residues (water, 20% ethanol for oil food)

Evaporation Residues (water)----for rubber pacifiers

Phenol in 4% acetic acid(Elution)

Formaldehyde in 4% acetic acid (Elution)

Zinc in 4% acetic acid (elution)

Zinc in water(elution)

Nitrosamine and nitrosatable substances (only for rubber nipple)

纸制品

Paper /processed paper

PCBs(AC 1221, AC1232, AC 1242, AC1248, AC1254, AC1260)

Total lead

Total Cadmium

Total Mercury

Total Chromium(VI)

As in 4% acetic acid (elution)

Heavy metal as lead in 4% acetic acid (Elution)

Evaporation Residues

Formaldehyde in water (Elution)

flurescent matter

Metal containers, packages and apparatus 金属容器/包装/设备

Pb, Cd, Ni in water(food pH >5) or 0.5% citric acid(food pH <5)

Cr(VI) in in water(food pH >5) or 0.5% citric acid(food pH <5)

As in 4% acetic acid

Evaporation Residues (water)

Evaporation Residues (4% acetic acid)

Evaporation Residues (20% ethanol)

Evaporation Residues (n-heptane)

formaldehyde in 4% acetic acid (elution)(with coating)

Vinylchloride Monomer(Elution)

Epichlorohyfrin(Elution)

BPA(Elution-include phenol, BPA, pt-butylphenol)

BPA diglycidyl ether(elution)

BPA F diglycidyl ether(elution)

Wood 木头

As in water (elution)

Heavy metal as lead in water (Elution)

sulfur dioxide in water (elution)

ortho-phenylphenol in 20% ethanol(elution)

thiabendazole in 20% ethanol(elution)

biphenyl in 20% ethanol(elution)

imazalil in 20% ethanol (elution)

玻璃 , 陶瓷 glass, ceramic, enamel, pottery

Cadmium(Elution)

Lead(Elution)

As (elution)(only for pottery)

淀粉 starch

lead

cadmium

Total Mercury

Total Chromium(VI)

As in water(elution)

Heavy metal as lead in 4% acetic acid (Elution)

formaldehyde in 4% acetic acid (elution)

Consumption of Potassium Permanganate(Elution)

flourescent matter